



AF / ERW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 3722**
Tadakatsu SUZUKI : Docket No. 2004_0477
Serial No. 10/807,189 : Group Art Unit 1775
Filed March 24, 2004 : Examiner Cathy F. Lam
LOW-REFLECTIVE THIN-FILM SUBSTRATE **Mail Stop: AF**

REQUEST TO WITHDRAW FINALITY OF REJECTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The Office Action mailed June 14, 2005, which constitutes a final rejection, includes a rejection of claim 17 based on the phrase "a thin film formed in multilayer". This phrase was present in original claim 2, and was also present in new claim 17 in the Supplemental Preliminary Amendment filed June 18, 2004 (which canceled claims 1-16). The Office Action of December 2, 2004 did not include a rejection based on this phrase in claim 17. Therefore, the current rejection of claim 17 on the basis of this phrase constitutes a new ground of rejection, which was not necessitated by Applicant's previous Amendment. Accordingly, the Office Action should not have constituted a final rejection. Applicant respectfully requests that the finality of the rejection be withdrawn.

Respectfully submitted,

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